



注释:

1. OPERATION WAVELENGTH: 250 nm–600 nm
2. CLEAR APERTURE (S1, S2, S3) : >70%CA
3. ANGLE TOLERANCE: ≤ 3 arcmin
4. SURFACE QUALITY (S1, S2, S3) : 40/20 (S/D)
5. SURFACE FLATNESS (S1, S2, S3) : $\lambda/10@632.8$ nm
6. CHAMFER: <0.2 mm, 45°
7. COATING (S3) : UV ENHANCED ALUMINUM (UVAL)
Ravg>90%@250 nm–600 nm, 45° AOI
8. OTHER SURFACES: FINE GROUND

DRAWING PROJECTION			LBTEK			
	NAME	DATE	RAP120-UVAL			
DRAWN	LTAN	Jul./30th/25	LxH=20.0mmx20.0mm, UVAL: 250–600 nm			
APPROVAL	WZCHENG	Jul./30th/25	MATERIAL	WEIGHT	SCALE	REV
FOR INFORMATION ONLY NOT FOR MANUFACTURING PURPOSES			N-BK7	10.0g	3:1	A